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Electronic Supplementary Material

Effect of Plasma treatment on multilayer Graphene: X-Ray Photoelectron Spectroscopy, Surface morphology investigations and work function measurements

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Figure S1:



Figure S1: (a) IV curve at different temperatures and (b) current Vs temperature plot for sample A1.

Figure S2:



Figure S2: IV curve at different temperatures (a, c, e and g) and current Vs temperature (b, d, f and h) plots for sample A2, B1, C1 and D1 respectively.

Figure S3:



Figure S3: IV curve at different temperatures (a, c and e) and current Vs temperature (b, d and f) plots for sample I1, I2 and I3 respectively.

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Figure S4:



Figure S4: Work function plots for pristine and different plasma treated MLG samples carried out using Kelvin probe method.

Table S1:

Sample code	Bulk concentration (/cm³) X10 ²¹	Mobility (cm²/Vs)	Resistivity (Ω.cm)	Conductivity (1/Ω cm)	Hall coefficient (cm ³ /C) X10 ⁻³
A1	-4.421	11.87	1.190X10 ⁻⁴	8.405X10 ³	-1.412
A2	3.103	7.453	2.699X10 ⁻⁴	3.705X10 ³	1.977
B1	0.8111	2.743	2.805X10 ⁻⁴	3.565X10 ³	7.695
C1	-0.3198	70.08	2.786X10 ⁻⁴	3.590X10 ³	-19.52
D1	-0.2663	68.30	3.432 X10 ⁻⁴	2.941X10 ³	-23.44
11	-0.2537	3.912X10⁻ ⁶	6.290X10 ³	1.590X10 ⁻⁴	-24.61
12	-0.5185	0.4327	2.782X10 ⁻⁴	3.595X10 ³	-12.04
13	-1.171	8.173	6.521X10 ⁻⁴	1.533X10 ³	-5.330

Table S1: Hall measurement results for pristine and plasma treated MLG samples.